

IN THE CLAIMS:

1. (Previously Presented) A composition for chemical mechanical planarization comprising an aqueous solution of ozone and abrasive particles, wherein a concentration of said ozone in said aqueous solution is between 1 to about 20 parts per million.
2. (Original) A composition as in claim 1 wherein said abrasive particles are selected from the group consisting of alumina, silica, ceria, spinel, zirconia and mixtures thereof.
3. (Original) A composition as in claim 1 further comprising at least one additive selected from the group consisting of carbonate, bicarbonate, oxalic acid, formic acid, acetic acid, glycol acids and mixtures thereof.
4. (Canceled)
5. (Canceled)
6. (Original) A composition as in claim 1 further comprising at least one ammonium salt.
7. (Original) A composition as in claim 6 wherein said at least one ammonium salt is ammonium carbonate.
8. (Previously Presented) A composition as in claim 1 wherein said abrasive particles are selected from the group consisting of alumina, ceria, spinel, zirconia and mixtures thereof.
9. (Previously Presented) A composition as in claim 1 further comprising at least one additive selected from the group consisting of bicarbonate, oxalic acid, formic acid, glycol acids and mixtures thereof.
10. (Previously Presented) A composition as in claim 1 wherein said abrasive particles are spinel.